



IFW

Atty. Dkt. No. 064951-0204

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Robert BELLMAN et al.
Title: USING DEUTERATED SOURCE
GASSES TO FABRICATE LOW
LOSS GeSiON SiON
WAVEGUIDES
Appl. No.: 10/608,432
Filing Date: 6/30/2003
Examiner: H. Hyeon
Art Unit: 2839

REQUEST FOR RECONSIDERATION AND REPLY UNDER 37 C.F.R. § 1.111

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This communication is responsive to the Non-Final Office Action dated April 20, 2005, concerning the above-referenced patent application.

Remarks/Arguments begin on page 2 of this document.